## Acknowledgement to Reviewers of Processes in 2015

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The editors of Processes would like to express their sincere gratitude to the following reviewers for assessing manuscripts in 2015. [...]

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## **Acknowledgement to Reviewers of Processes in 2015**

## Processes Editorial Office,

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The editors of *Processes* would like to express their sincere gratitude to the following reviewers for assessing manuscripts in 2015.

We greatly appreciate the contribution of expert reviewers, which is crucial to the journal's editorial decision-making process. Several steps have been taken in 2015 to thank and acknowledge reviewers. Good, timely reviews are rewarded with a discount off their next MDPI publication. By creating an account on the submission system, reviewers can access details of their past reviews, see the comments of other reviewers, and download a letter of acknowledgement for their records. In addition, MDPI has launched a collaboration with Publons, a website that seeks to publicly acknowledge reviewers on a per journal basis. This is all done, of course, within the constraints of reviewer confidentiality. Feedback from reviewers shows that most see their task as a voluntary and mostly unseen work in service to the scientific community. We are grateful to our reviewers for the contribution they make.

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